MEMS光制御技術の研究動向 (静電マイクロアクチュエータの光学応用)

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> 1. MEMS = Micro Electro Mechanical Systems

- 2. µ-Actuator for Astronomy
- 3. MEMS at the Beginning = Fiber Telecom
- 4. Theory of Electrostatic Force
- 5. More Added Values
- 6. Summary



CMOS-MEMSマイクロミラーはじめました



Projection Display in 1975

R. N. Thomas, J. Guldberg, H. C. Nathanson, P. R. Malmberg, IEEE Trans. ED vol. 22, 1975, Westinghouse Research Labs & Philips



A True Micro Motor, Diameter 120 microns



Y.Tai et al. Sensors & Actuators 1989



MEMS Micro Actuators

MEMS = Micro Electro Mechanical Systems



MEMS Actuators for Optical Applications

Interactive Image Displays



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Multi-Slit Array for Observatory

TAO in Atacama (5639 m)





Co. Chajnantor (5639m)





HIGH CONTRAST, CRYOGENIC, LARGE MICROMIRROR ARRAY FOR MULTI-OBJECT SPECTROSCOPY

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Figure 1. 64 x 32 micromirror array with high fill factor in one direction, providing long slits. Each mirror measures 200 x $100 \ \mu m^2$. Array surface picture and packaged device.

Electromagnetic MEMS Shutter for NASA JWST

Li et al., "Microshutter array development for the James Webb space telescope," (2005) SPIE 5650 9

- For satellite mount
- Open Electromagnetically
- Latch Electrostatically
- Matrix 64 × 128
- Size 100 µm × 200 µm





単位面積あたり発生力

	静電駆動	電磁駆動	圧電駆動 (磁歪・電歪駆動)	熱膨張 (通電加熱)
原理図		W W B B		
単位面積 あたりの 発生力 (N/m ²)	(1/2) $\epsilon_0 E^2$	<i>I B /</i> w	Εε	$\boldsymbol{E} \boldsymbol{\alpha} \Delta \boldsymbol{T}$
	$E:$ 電場 $oldsymbol{arepsilon}_0:$ 誘電率	<i>I</i> :駆動電流 <i>B</i> :磁束密度 <i>w</i> :線幅	<i>E</i> : ヤング率 <i>ε</i> : 歪	<i>E</i> :ヤング率 α:線膨張系数 Δ <i>T</i> :温度変化
	10 ¹ ~10 ⁴ N/m ²	10 ¹ ~10 ³ N/m ²	圧電 10 ⁷ ~10 ⁸ N/m ² 電歪 10 ⁷ ~10 ⁹ N/m ²	10 ⁶ ∼10 ⁸ N/m ²
代表的 設計値	静電ギャップ g = 1 ~ 10 µm 駆動電圧 V = 1 ~ 100 V	永久磁石 <i>H_c~10 kOe</i>	ヤング率 <i>E</i> ~ 100 GPa	ヤング率 <i>E</i> ~ 100 GPa
		駆動電流 <i>I</i> =1 mA~1 A	圧電の機械歪 <i>ε</i> = 0.01 ~ 0.1 %	線膨張係数 α~1 0 ppm
		配線幅 w~10 μm	磁歪、電歪の機械歪 <i>ε</i> = 0.01 ~ 1 %	温度変化 Δ <i>T</i> = 1 ~ 100 ℃

Optical MEMS Shutter Array at UTokyo

W 100 um x L 1000 um



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MEMS VOA Application in Fiber Telecom Network



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Simple Structures and Process for VOA



SOI Bulk Micromachining by DRIE



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Attenuation Control and Complete Block-out

Normally-Bright Mode



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電圧印加 → 静電引力 → 機械的変形





Electrostatic micro actuator (bi-directional)



第1問 電極間を接続するとどうなるでしょう?







正解と解説



この原理の応用例: 可動構造と基板を等電位に接地して、下向きの動きを防止。







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http://www.kenis.co.jp/

だまされてませんでしたか?



ただし、等電位であっても静電反発力は働く。





第3問 静電反発力を使わない理由は?

どっちもクーロンカ、電荷の量は同じ、符号が違うだけ

$$F = \frac{1}{4 \pi \varepsilon_0} \cdot \frac{Q_1 \cdot Q_2}{r^2}$$







静電反発力アクチュエータ

解説駆動電圧が高いのは損

電場に逆らって電荷を移動した仕事が「電位」

$$V = E_n \cdot r = \frac{\sigma}{2 \varepsilon_0} \cdot r$$



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Optically Powered Fiber Endoscope



Application of WDM Technology



Electrostatic MEMS Optical Scanner 2 mm x 3 mm



Assembly of MEMS Endoscope Head



-GRIN Lens

-Photovoltaic Cell



Detail View of Optically Powered OCT



OCT (Optical Coherence Tomography) Image

2.3 mm



M. Nakada, et al., "Optical Coherence Tomography based on Power-overfiber MEMS Scanner," *APCOT 2008,* Jun. 22-25 2008.

	Scan Range	Resolution
	(mm)	(um)
Lateral	1.6	40
Depth	1.0 ~ 2.5	8





Wavelength-Tunable Laser for OT



Two OCT Operation Principles



Advantages of SS-OCT



MEMS Scanner to Replace Polygon Mirrors



Fast Operation Speed at 70 kHz







External Cavity Laser for Wavelength Tuning



Wavelength Scan Performance

Mechanical 70 kHz x round-trip scan → 140 kHz Sweep Band Width ~ 100 nm



Intensity calibration required for OCT imaging

santec

Virtually Slicing Alive





Higher resolution, less invasive, and less expensive than X-ray CT or Ultrasonic Imagers



Benefits of Fast OCT Scan

Higher Resolution & Faster Frame Rate







santec



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Wavelength-Tunable Laser for OT



MEMS-based Tunable VCSEL

1060 nm wavelength range with InGaAs/GaAs



Keiji Isamoto, Kiyotaka Yamashita, Mohammed Saad Khan, Nicolas Lafitte, Kouki Totsuka, Changho Chong, Nobuhiko Nishiyama, and Hiroshi Toshiyoshi, "A MEMS based electrically pumped tunable VCSEL operating at 1060nm for SS-OCT," SPIE Photonics West 2015 -- MOEMS and Miniaturized Systems XIV --, Feb. 9-12, 2015, The Moscone Center, San Francisco, CA.

MEMS-based Tunable VCSEL

Device Package (Front / Rear)



Wavelength Tuning Performance

Coherence Length > 100 nm to probe deep inside



Output Intensity (Time = Wavelength)

Benefits of Long Coherence Length

Visualizing Long Distance ... in particular for ophthalmologic examination



ZUKHZ Operation

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Imaging Depth Scaling

At 500 MHz data sampling with a 50% duty cycle



OCT over a Distance (~ 1 m)

 $\Delta \lambda = 4 \text{ nm} \rightarrow d \sim 10 \text{ cm}$





OCT over a Distance (~ 1 m)

 $\Delta \lambda = 4 \text{ nm} \rightarrow d \sim 10 \text{ cm}$



Overall OCT System Performance

	Experimental Results	Note		
Scan Speed	140 kHz	Round-Trip Scan		
Band Width	100 nm			
OCT Resolution	9 µm	1310 nm		
Spectrum Width	0.25 nm			
Coherence Length	3 mm	(in Air)		
Maximum Power	20 mW			
Dynamic Range 60 dB		3 = =		
Vavelength Tunable Laser				

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